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- 1) Le-The, H., Berenschot, E., Tiggelaar, R.M., Tas, N.R., van den Berg, A., Eijkel, J.C.T.
[Correction to: Shrinkage Control of Photoresist for Large-Area Fabrication of Sub-30 nm Periodic Nanocolumns \(Advanced Materials Technologies, \(2017\), 2, 3, \(1600238\), 10.1002/admt.201600238\)](#)
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